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Xing Zhu
Stephen Y. Chou
Yasuhiko Arakawa
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Contents

vii	Conference Committee
ix	Symposium Committees

SESSION 1 NEAR-FIELD OPTICS AND SURFACE PLASMON POLARITON

- 6831 02 **Micro-cylinder mode in photonic quasicrystal observed by near-field optical microscopy** [6831-53]
Z. Fang, T. Dai, B. Zhang, X. Zhu, Peking Univ. (China)
- 6831 03 **Large Goos-Hänchen displacement of evanescent light beam in near-field enhanced configuration** [6831-17]
Y. Zhang, Shanghai Univ. (China); C.-F. Li, Shanghai Univ. (China) and Xi'an Institute of Optics and Precision Mechanics (China); X. Chen, Shanghai Univ. (China)
- 6831 04 **Analysis of resonant properties in surface plasmon polaritons nanocavities** [6831-01]
C. Hu, J. Liu, F. Sun, G. Zhang, Y. Liu, Beijing Jiaotong Univ. (China)
- 6831 05 **Evolution of microscopic interaction force and interpretation for major well-known optical phenomenon and experiments** [6831-07]
R. Zhu, China Metrology Institute Hangzhou (China); L. Zhu, The Second Hospital of Zhejiang Univ. (China); T. Wei, Y. Shi, China Metrology Institute Hangzhou (China)
- 6831 06 **Near-field intensity distribution from a bow-tie aperture VCSEL with its polarization state improved** [6831-57]
H. Gai, J. Wang, Q. Tian, Tsinghua Univ. (China); W. Xia, X. Xu, Shandong Univ. (China)

SESSION 2 METAMATERIALS

- 6831 08 **Nanometrology based on white-light spectral interferometry in thickness measurement** [6831-37]
H. Chen, T. Liu, Z. Meng, China Jiliang Univ. (China)
- 6831 09 **Single-negative negative index metamaterials with broad bandwidth** [6831-49]
J. Chen, Z. Fan, F. Yang, Institute of Semiconductors (China)

SESSION 3 PHOTONIC CRYSTALS

- 6831 0D **An ultracompact refractive index gas-sensor based on photonic crystal microcavity** [6831-16]
X. Wang, Beijing Univ. of Posts and Telecommunications (China) and Beijing Institute of Machinery (China); N. Lu, Beijing Institute of Machinery (China); J. Zhu, G. Jin, Tsinghua Univ. (China)

- 6831 OE **Comment on properties of one-dimensional photonic crystals containing negative refraction materials** [6831-24]
C. Hu, Y. Xu, H. He, South China Normal Univ. (China)

SESSION 4 OPTICAL CHARACTERIZATION

- 6831 OG **Simulation of optical surfaces and their PSD study** [6831-30]
S. Gan, Univ. of Science and Technology of China (China) and Hefei Univ. of Technology (China); Y. Bao, Hefei Univ. of Technology (China); Y. Hong, X. Xu, Y. Liu, S. Fu, Univ. of Science and Technology of China (China)
- 6831 OH **The specimen preparation methods for nano-indentation testing of biomaterials: a review** [6831-18]
J. Y. Sun, J. Tong, Z. J. Zhang, Jilin Univ. (China)
- 6831 OI **Improvement on thickness uniformity of large-area DLC thin films deposited by femtosecond pulsed laser** [6831-40]
J. Liu, Huazhong Univ. of Science and Technology (China) and High Speed Aerodynamics Institute of China (China); G. Zhang, X. Yuan, Huazhong Univ. of Science and Technology (China)
- 6831 OJ **Investigation on the laser transmission properties of nanofluids** [6831-06]
M. Qian, Z. Shen, J. Lu, X. Ni, Q. Li, Y. Xuan, Nanjing Univ. of Science and Technology (China)

SESSION 5 CALCULATION OF NANOSTRUCTURES

- 6831 OO **The energy levels of a nanoring in the presence of quantum barriers** [6831-25]
E. Faizabadi, K.N. Toosi Univ. of Technology (Iran) and Iran Univ. of Science and Technology (Iran); S. Ahmadi, P. Robat Sarpooshi, K.N. Toosi Univ. of Technology (Iran)
- 6831 OR **High efficiency fiber to waveguide optical coupler in silicon-on-insulator based slot waveguides** [6831-43]
Y. Liu, S. Chen, J. Yu, Institute of Semiconductors (China)
- 6831 OT **Confined optical fields based on surface plasmon polaritons** [6831-56]
Q. Wang, J. Wang, S. Zhang, Tsinghua Univ. (China)

SESSION 6 QUANTUM DOTS

- 6831 OU **Luminescent CdTe/CdS core-shell and CdTe/CdS/ZnS multi-layer quantum dots: synthesis and investigations for bio-application** [6831-20]
S. Xu, J. Zhang, X. Song, Z. Dai, Tianjin Polytechnic Univ. (China); B. Sun, Nankai Univ. (China)
- 6831 OV **Surface enhanced Raman scattering activity of core-shell Au nanoparticle film** [6831-08]
X. Hong, D. Du, Tianjin Univ. (China)

6831 0W **Mechanisms of plasmon-induced charge separation and recombination at gold nanoparticle supported on different size TiO₂ film systems** [6831-19]
L. Du, A. Furube, K. Hara, R. Katoh, M. Tachiya, National Institute of Advanced Industrial Science and Technology (Japan)

6831 0X **Electronic states in an infinite one-dimensional random binary quantum wire in the presence of electric field** [6831-41]
E. Faizabadi, Iran Univ. of Technology (Iran) and K.N. Toosi Univ. of Technology (Iran)

POSTER SESSION

6831 10 **Effect of scatterers shape between coupling channels on the photonic crystal coupler** [6831-02]
C. Guan, L. Yuan, Harbin Engineering Univ. (China)

6831 11 **Properties of ITO thin films prepared by APS-assisted EB evaporation** [6831-05]
G. He, C. Xiong, X. Yao, Huazhong Institute of Opto-Electronics (China)

6831 13 **Influence of SDBS on stability of Al₂O₃ nano-suspensions** [6831-11]
X.-J. Wang, South China Univ. of Technology (China) and Navy Arms of Services Command Academy (China); X.-F. Li, N. Wang, South China Univ. of Technology (China); X.-Y. Wen, Q. Long, Navy Arms of Services Command Academy (China)

6831 14 **The surface treatment of silicon wafer by microwave down-stream plasma etching** [6831-13]
H. Ju, Nagoya Univ. (Japan); W. Wang, The Hong Kong Polytechnic Univ. (Hong Kong China)

6831 15 **Threshold behavior of defect modes in one-dimensional active photonic crystal** [6831-14]
Y. Han, Huazhong Univ. of Science and Technology (China) and China Univ. of Geosciences (China); H. Wang, Shenzhen Univ. (China) and Univ. of Electronic Science and Technology of China (China); Z. Ouyang, Shenzhen Univ. (China)

6831 16 **Dispersion-induced localized modes in weakly random media** [6831-15]
Y. Han, China Univ. of Geosciences (China); H. Wang, Shenzhen Univ. (China) and Univ. of Electronic Science and Technology of China (China); Z. Ouyang, Univ. of Electronic Science and Technology of China (China)

6831 17 **Thermal treatment for tuning the lasing wavelength of quantum dot laser diodes** [6831-23]
K. W. Kim, Korea Institute of Science and Technology (South Korea) and Korea Univ. (South Korea); M. H. Park, Korea Univ. (South Korea); K. W. Jung, S. P. Ryu, N. K. Cho, J. Y. Lim, S. J. Park, J. D. Song, W. J. Choi, J. I. Lee, Korea Institute of Science and Technology (South Korea); J. H. Park, Korea Univ. (South Korea)

6831 18 **Accurate vibration detection of a rough surface** [6831-26]
H. Zeng, Y. Zhou, S. Fan, J. He, Institute of Semiconductors (China)

6831 19 **Fabrication of InGaN quantum dots by periodically interrupted growth in MOCVD** [6831-28]
S.-K. Choi, J.-M. Jang, S.-H. Yi, J.-A. Kim, W.-G. Jung, Kookmin Univ. (South Korea)

- 6831 1A **Properties of aluminum doped zinc oxide thin film by sol-gel process** [6831-29]
S.-H. Yi, S.-K. Choi, J.-M. Jang, J.-A Kim, W.-G. Jung, Kookmin Univ. (South Korea)
- 6831 1B **Fabrication of CoFe nanostructures by holographic lithography** [6831-31]
Z. Zhang, X. Wang, Y. Liu, Y. Guo, Y. Hong, X. Xu, S. Fu, P. Xu, J. Wang, Univ. of Science and Technology of China (China); J. Cai, Institute of Physics and Ctr. of Condensed Matter Physics (China)
- 6831 1C **Light emission from controlled multilayer comprising of thin amorphous and nanocrystalline silicon carbide layers** [6831-32]
W. Yu, L. Li, Y. Li, J. Du, X. Ding, S. Cui, G. Fu, Hebei Univ. (China)
- 6831 1D **Realization of super narrow pass-band and super narrow transmission-angle filters with one-dimensional defective photonic crystal hetero-structures** [6831-33]
D. Mao, Z. Ouyang, Y. Zhong, Shenzhen Univ. (China) and Shenzhen Key Lab. of Micro-Nano-Photonics Information Technology (China)
- 6831 1E **Structural and optical properties of doped silicon nanocrystals: first-principles calculation** [6831-42]
G. Fu, H. Gao, W. Lu, W. Ding, W. Yu, Hebei Univ. (China)
- 6831 1F **Optical modulator using silicon photonic crystals/nano-montmorillonite** [6831-47]
J. Li, J. Li, X. Wang, China Jiliang Univ. (China)
- 6831 1G **Influence of nano-scale dimension on properties of transmission in metallic gratings with narrow slits** [6831-52]
Y. Cao, P. Wang, C. Min, H. Ming, Univ. of Science and Technology of China (China)
- 6831 1K **New formalism in evaluation of the ground and few excited states of Hubbard chain nanostructures** [6831-39]
E. Faizabadi, Iran Univ. of Science and Technology (Iran) and K.N. Toosi Univ. of Technology (Iran); M. Soleimani, K.N. Toosi Univ. of Technology (Iran)

Author Index

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- 1 Near-Field Optics and Surface Plasmon Polariton
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- 2 Metamaterials
Jia Wang, Tsinghua University (China)
- 3 Photonic Crystals
Edris Faizabadi, K.N. Toosi University of Technology (Iran)
- 4 Optical Characterization
Jia Wang, Tsinghua University (China)
- 5 Calculation of Nanostructures
Jiaren Liu, National Research Council Canada (Canada)
- 6 Quantum Dots
Xing Zhu, Peking University (China)

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